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## INFORMATION CITED BY APPLICANTS THAT MAY BE MATERIAL TO THE PROSECUTION OF THE SUBJECT APPLICATION

Applicants:

L.W. Graham et al.

Attorney Docket No.: SEMT116060

Application No.: 09/429,446

Group Art Unit: 1741

Filed:

October 28, 1999

Examiner: W. Leader

Title:

METHOD, CHEMISTRY, AND APPARATUS FOR NOBLE METAL

ELECTROPLATING ON A MICROELECTRONIC WORKPIECE

## **U.S. PATENT DOCUMENTS**

*Examiner	Cite		Kind	Date	
Initials	No.	Document No.	Code	(mm/dd/yyyy)	Name
Wh	_ U20	5,789,320		08/04/1998	Andricacos et al.

Examiner

Date Considered

9/2002

\*Examiner: Initial if reference considered, whether or not citation is in conformance with M.P.E.P. § 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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